

Micronic receives order for an FPS5100 for advanced electronic packaging applications

Täby, Sweden – October 1, 2008 – Micronic Laser Systems AB (OMX Nordic Exchange Stockholm, Nordic list, Small Cap, Information Technology: MICR), today received an order for an FPS5100 from a customer in Asia. The system will be delivered during first half of 2009.

”We look forward to our deepened co-operation with this important customer,” said Sven Löfqvist, president and CEO of Micronic Laser Systems AB. “The system, with its field-proven stability, delivers the throughput and photomask quality needed to meet the increasing demands within electronic packaging”.

The FPS5100 enables high-volume production of photomasks for advanced electronic packaging, passive matrix TN/STN LCDs and other large-area applications. The system provides shorter turn-around times, easier production planning and the lowest cost of ownership within its application space.

Company contact:

Sven Löfqvist
President & CEO
Tel: +46 8 638 52 00
sven.lofqvist@micronic.se

About Micronic Laser Systems AB

Micronic Laser Systems AB is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic’s product offering also includes metrology systems for display photomasks. Micronic’s systems are used by the world’s leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States, Japan, South Korea and Taiwan. Micronic maintains a web site at: <http://www.micronic.se>